

DATA SHEET

BF1100WR Dual-gate MOS-FET

Product specification
File under Discrete Semiconductors, SC07

1995 Apr 25

Philips Semiconductors



PHILIPS

Dual-gate MOS-FET

BF1100WR

FEATURES

- Specially designed for use at 9 to 12 V supply voltage
- Short channel transistor with high forward transfer admittance to input capacitance ratio
- Low noise gain controlled amplifier up to 1 GHz
- Superior cross-modulation performance during AGC.

APPLICATIONS

- VHF and UHF applications such as television tuners and professional communications equipment.

DESCRIPTION

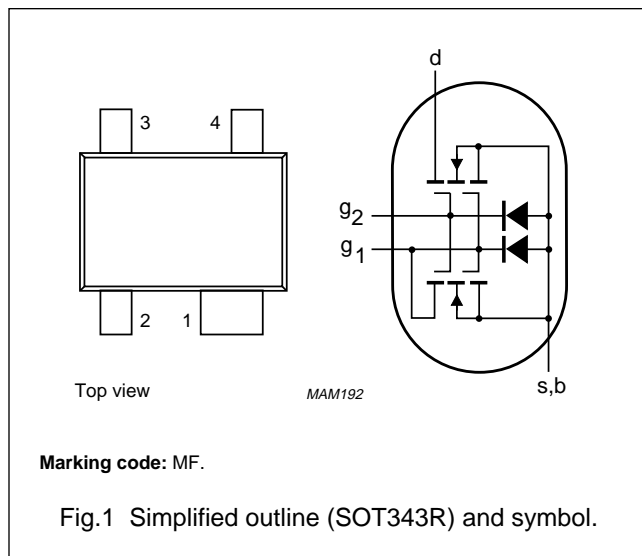
Enhancement type field-effect transistor in a plastic microminiature SOT343R package. The transistor consists of an amplifier MOS-FET with source and substrate interconnected and an internal bias circuit to ensure good cross-modulation performance during AGC.

CAUTION

The device is supplied in an antistatic package. The gate-source input must be protected against static discharge during transport or handling.

PINNING

| PIN | SYMBOL | DESCRIPTION |
|-----|----------------|-------------|
| 1 | s, b | source |
| 2 | d | drain |
| 3 | g ₂ | gate 2 |
| 4 | g ₁ | gate 1 |



QUICK REFERENCE DATA

| SYMBOL | PARAMETER | CONDITIONS | MIN. | TYP. | MAX. | UNIT |
|--------------------|--------------------------------|-------------|------|------|------|------|
| V _{DS} | drain-source voltage | | – | – | 14 | V |
| I _D | drain current | | – | – | 30 | mA |
| P _{tot} | total power dissipation | | – | – | 280 | mW |
| T _j | operating junction temperature | | – | – | 150 | °C |
| y _{fs} | forward transfer admittance | | 24 | 28 | 33 | mS |
| C _{ig1-s} | input capacitance at gate 1 | | – | 2.2 | 2.6 | pF |
| C _{rs} | reverse transfer capacitance | f = 1 MHz | – | 25 | 35 | fF |
| F | noise figure | f = 800 MHz | – | 2 | – | dB |

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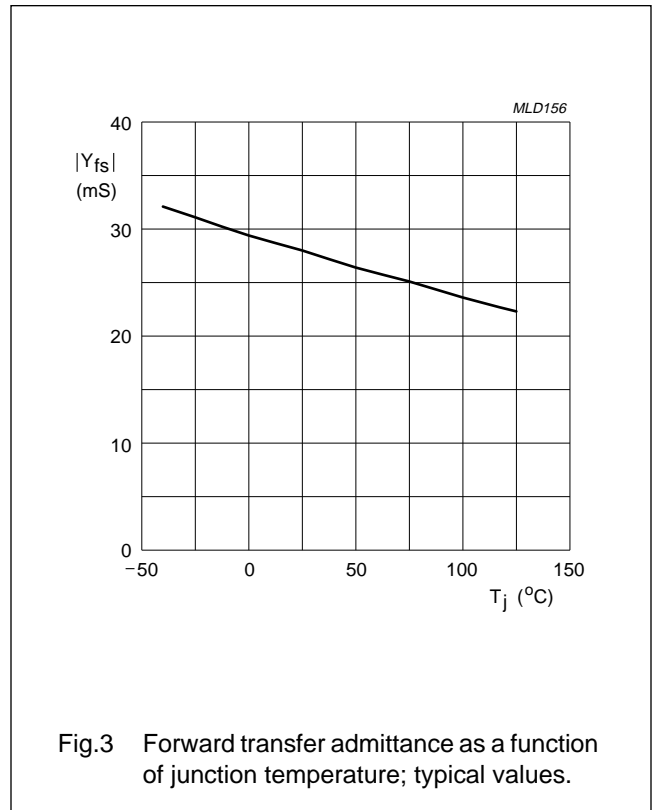
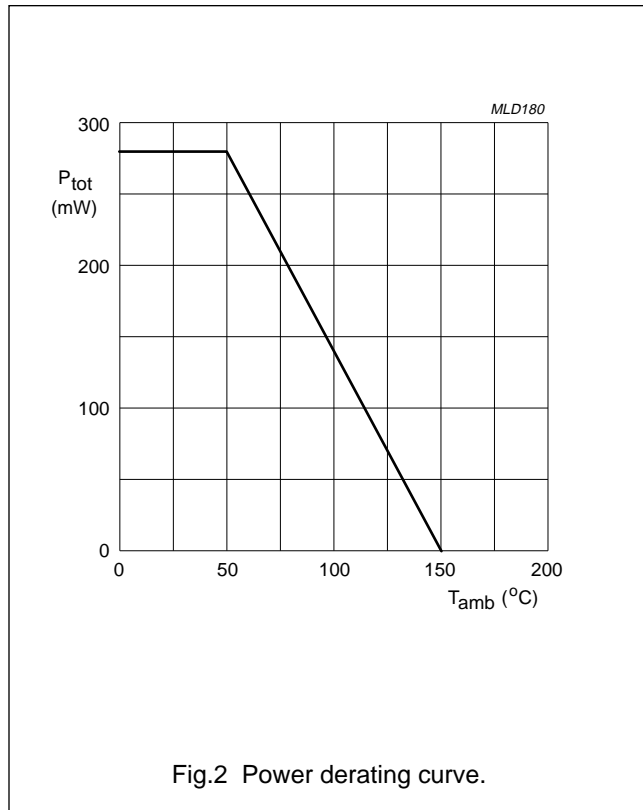
LIMITING VALUES

In accordance with the Absolute Maximum Rating System (IEC 134).

| SYMBOL | PARAMETER | CONDITIONS | MIN. | MAX. | UNIT |
|-----------|--------------------------------|--|------|----------|------------------|
| V_{DS} | drain-source voltage | | – | 14 | V |
| I_D | drain current | | – | 30 | mA |
| I_{G1} | gate 1 current | | – | ± 10 | mA |
| I_{G2} | gate 2 current | | – | ± 10 | mA |
| P_{tot} | total power dissipation | see Fig.2; up to $T_{amb} = 50\text{ }^\circ\text{C}$; note 1 | – | 280 | mW |
| T_{stg} | storage temperature | | –65 | +150 | $^\circ\text{C}$ |
| T_j | operating junction temperature | | – | +150 | $^\circ\text{C}$ |

Note

1. Device mounted on a printed-circuit board.



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THERMAL CHARACTERISTICS

| SYMBOL | PARAMETER | CONDITIONS | VALUE | UNIT |
|---------------|---|-------------------------------|-------|------|
| $R_{th\ j-a}$ | thermal resistance from junction to ambient | note 1 | 350 | K/W |
| $R_{th\ j-s}$ | thermal resistance from junction to soldering point | $T_s = 91\text{ °C}$; note 2 | 210 | K/W |

Notes

1. Device mounted on a printed-circuit board.
2. T_s is the temperature at the soldering point of the source lead.

STATIC CHARACTERISTICS

$T_j = 25\text{ °C}$; unless otherwise specified.

| SYMBOL | PARAMETER | CONDITIONS | MIN. | MAX. | UNIT |
|-----------------|---------------------------------|--|------|------|------|
| $V_{(BR)G1-SS}$ | gate 1-source breakdown voltage | $V_{G2-S} = V_{DS} = 0$; $I_{G1-S} = 1\text{ mA}$ | 13.2 | 20 | V |
| $V_{(BR)G2-SS}$ | gate 2-source breakdown voltage | $V_{G1-S} = V_{DS} = 0$; $I_{G2-S} = 1\text{ mA}$ | 13.2 | 20 | V |
| $V_{(F)S-G1}$ | forward source-gate 1 voltage | $V_{G2-S} = V_{DS} = 0$; $I_{S-G1} = 10\text{ mA}$ | 0.5 | 1.5 | V |
| $V_{(F)S-G2}$ | forward source-gate 2 voltage | $V_{G1-S} = V_{DS} = 0$; $I_{S-G2} = 10\text{ mA}$ | 0.5 | 1.5 | V |
| $V_{G1-S(th)}$ | gate 1-source threshold voltage | $V_{G2-S} = 4\text{ V}$; $V_{DS} = 9\text{ V}$; $I_D = 20\text{ }\mu\text{A}$ | 0.3 | 1 | V |
| | | $V_{G2-S} = 4\text{ V}$; $V_{DS} = 12\text{ V}$; $I_D = 20\text{ }\mu\text{A}$ | 0.3 | 1 | V |
| $V_{G2-S(th)}$ | gate 2-source threshold voltage | $V_{G1-S} = 4\text{ V}$; $V_{DS} = 9\text{ V}$; $I_D = 20\text{ }\mu\text{A}$ | 0.3 | 1.2 | V |
| | | $V_{G1-S} = 4\text{ V}$; $V_{DS} = 12\text{ V}$; $I_D = 20\text{ }\mu\text{A}$ | 0.3 | 1.2 | V |
| I_{DSX} | drain-source current | $V_{G2-S} = 4\text{ V}$; $V_{DS} = 9\text{ V}$; $R_{G1} = 180\text{ k}\Omega$; note 1 | 8 | 13 | mA |
| | | $V_{G2-S} = 4\text{ V}$; $V_{DS} = 12\text{ V}$; $R_{G1} = 250\text{ k}\Omega$; note 2 | 8 | 13 | mA |
| I_{G1-SS} | gate 1 cut-off current | $V_{G2-S} = V_{DS} = 0$; $V_{G1-S} = 12\text{ V}$ | – | 50 | nA |
| I_{G2-SS} | gate 2 cut-off current | $V_{G1-S} = V_{DS} = 0$; $V_{G2-S} = 12\text{ V}$ | – | 50 | nA |

Notes

1. R_{G1} connects gate 1 to $V_{GG} = 9\text{ V}$; see Fig.26.
2. R_{G1} connects gate 1 to $V_{GG} = 12\text{ V}$; see Fig.26.

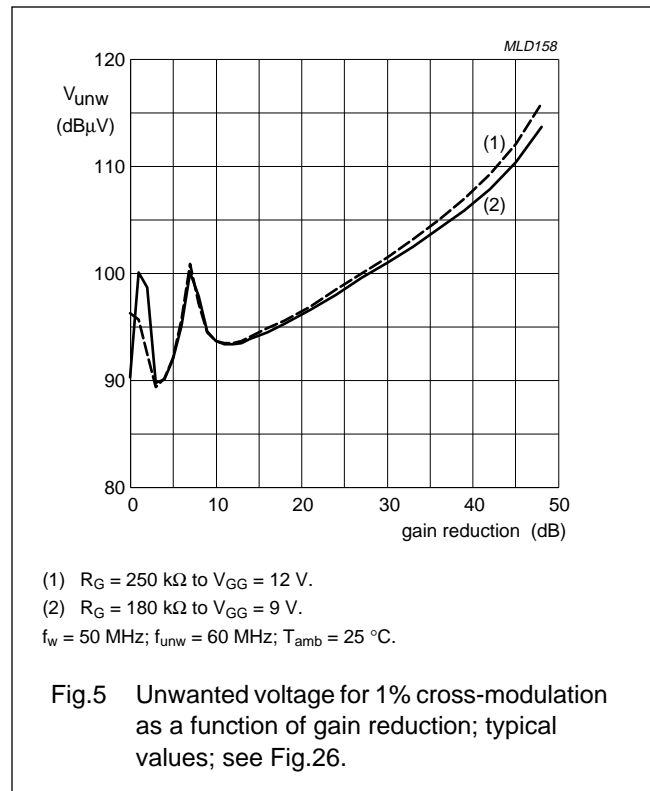
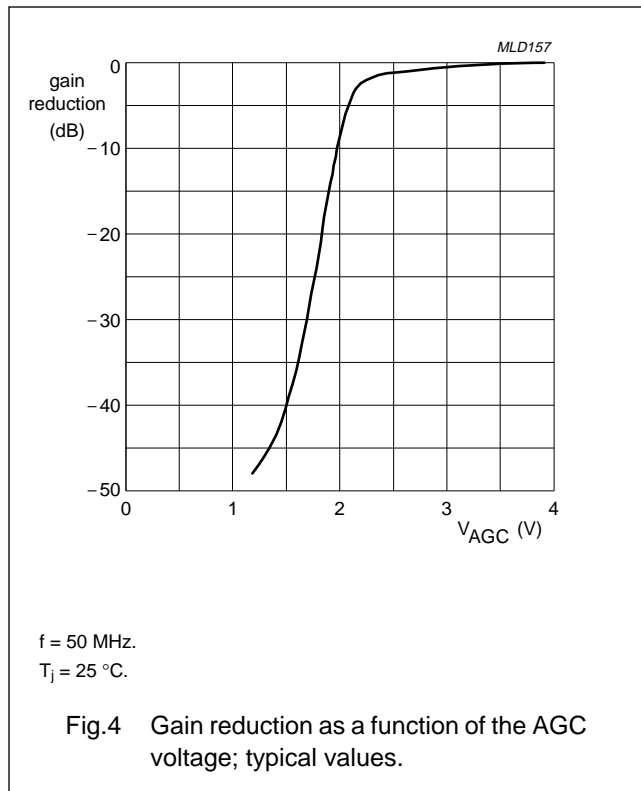
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DYNAMIC CHARACTERISTICS

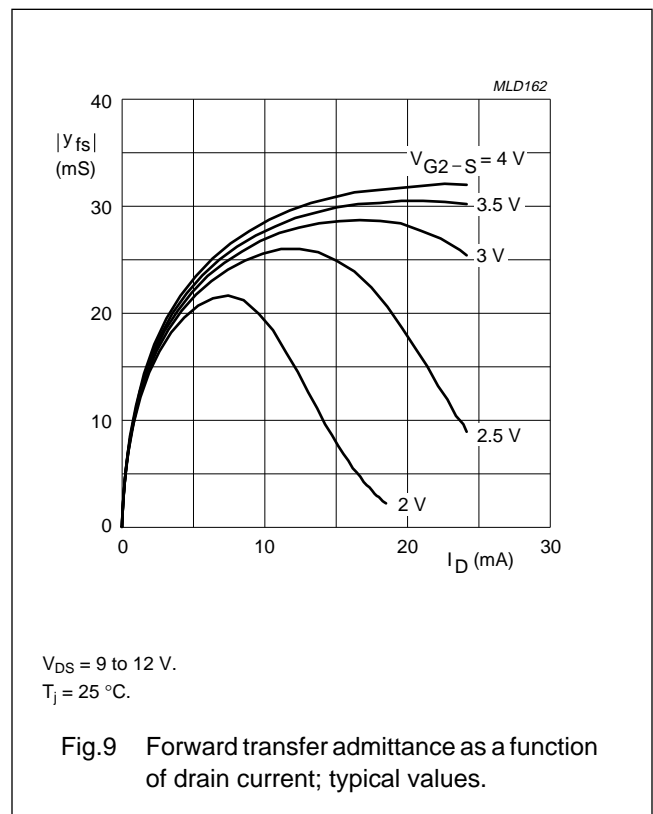
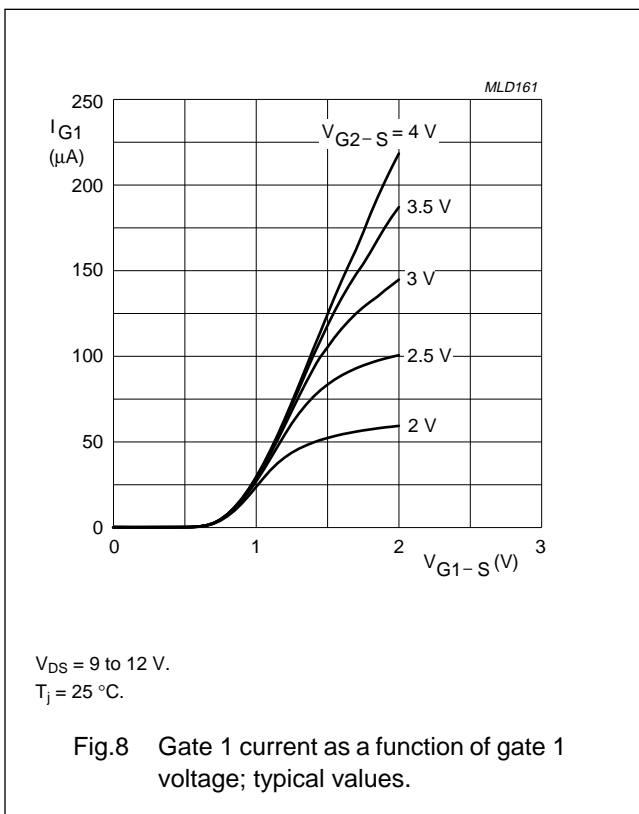
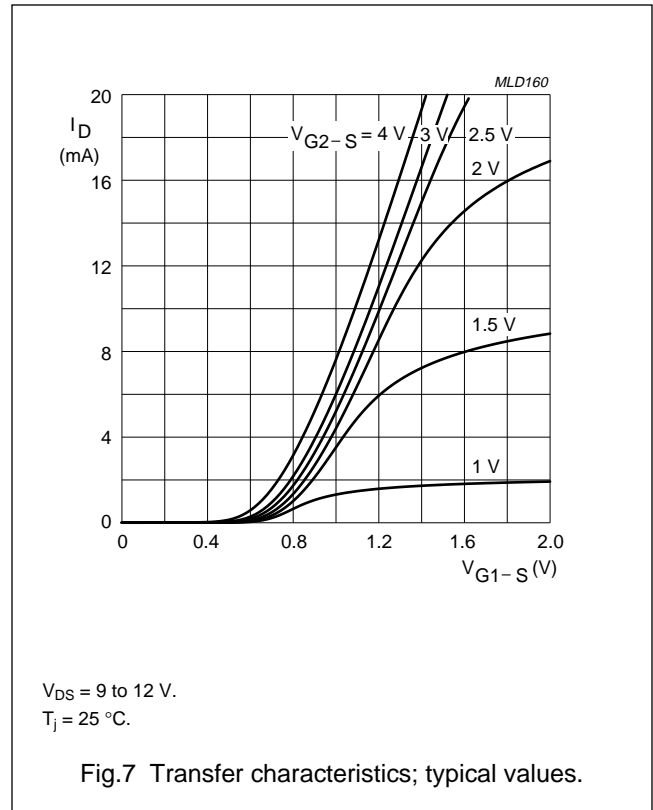
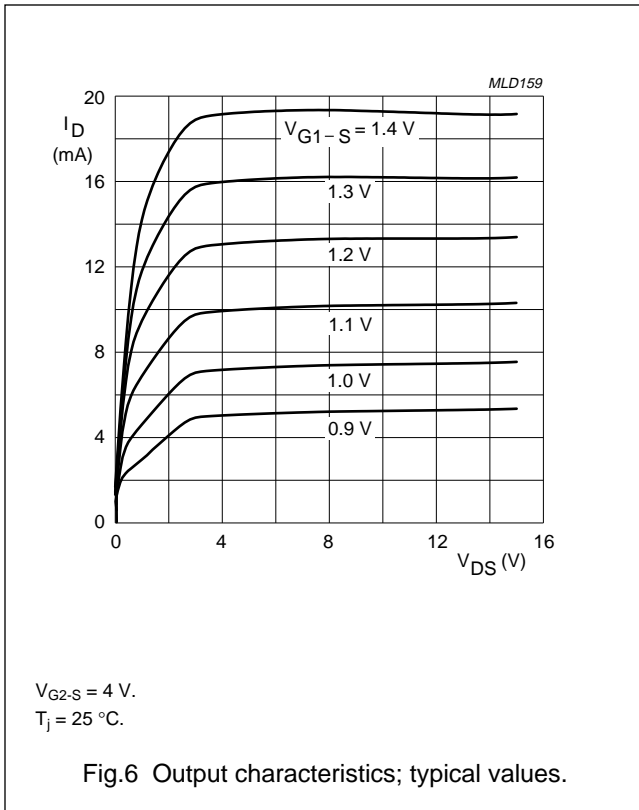
Common source; $T_{amb} = 25\text{ }^{\circ}\text{C}$; $V_{G2-S} = 4\text{ V}$; $I_D = 10\text{ mA}$; unless otherwise specified.

| SYMBOL | PARAMETER | CONDITIONS | MIN. | TYP. | MAX. | UNIT |
|-------------|------------------------------|---|------|------|------|------|
| $ y_{fs} $ | forward transfer admittance | pulsed; $T_j = 25\text{ }^{\circ}\text{C}$ $V_{DS} = 9\text{ V}$ | 24 | 28 | 33 | mS |
| | | $V_{DS} = 12\text{ V}$ | 24 | 28 | 33 | mS |
| C_{ig1-s} | input capacitance at gate 1 | $f = 1\text{ MHz}$ $V_{DS} = 9\text{ V}$ | – | 2.2 | 2.6 | pF |
| | | $V_{DS} = 12\text{ V}$ | – | 2.2 | 2.6 | pF |
| C_{ig2-s} | input capacitance at gate 2 | $f = 1\text{ MHz}$ $V_{DS} = 9\text{ V}$ | – | 1.6 | – | pF |
| | | $V_{DS} = 12\text{ V}$ | – | 1.4 | – | pF |
| C_{os} | drain-source capacitance | $f = 1\text{ MHz}$ $V_{DS} = 9\text{ V}$ | – | 1.4 | 1.8 | pF |
| | | $V_{DS} = 12\text{ V}$ | – | 1.1 | 1.5 | pF |
| C_{rs} | reverse transfer capacitance | $f = 1\text{ MHz}$ $V_{DS} = 9\text{ V}$ | – | 25 | 35 | fF |
| | | $V_{DS} = 12\text{ V}$ | – | 25 | 35 | fF |
| F | noise figure | $f = 800\text{ MHz}$; $G_S = G_{Sopt}$; $B_S = B_{Sopt}$ $V_{DS} = 9\text{ V}$ | – | 2 | 2.8 | dB |
| | | $V_{DS} = 12\text{ V}$ | – | 2 | 2.8 | dB |



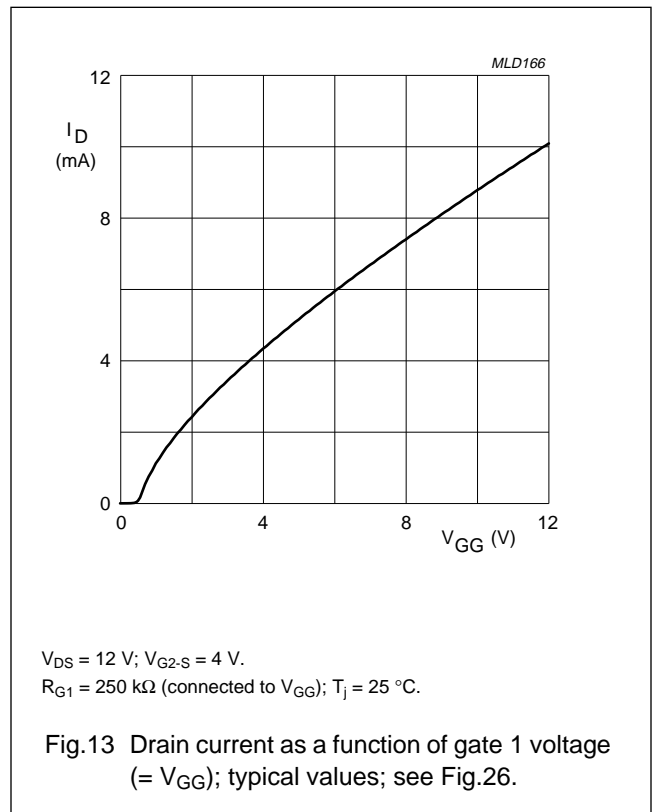
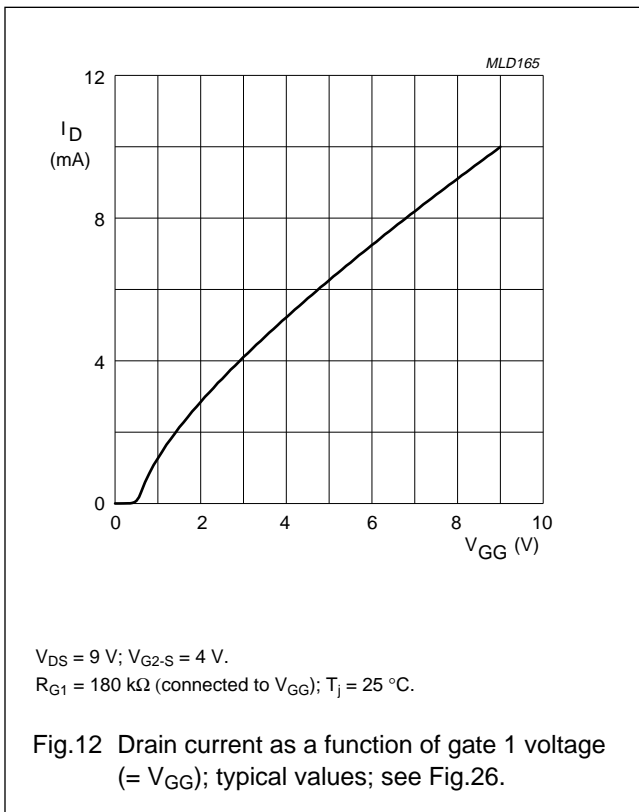
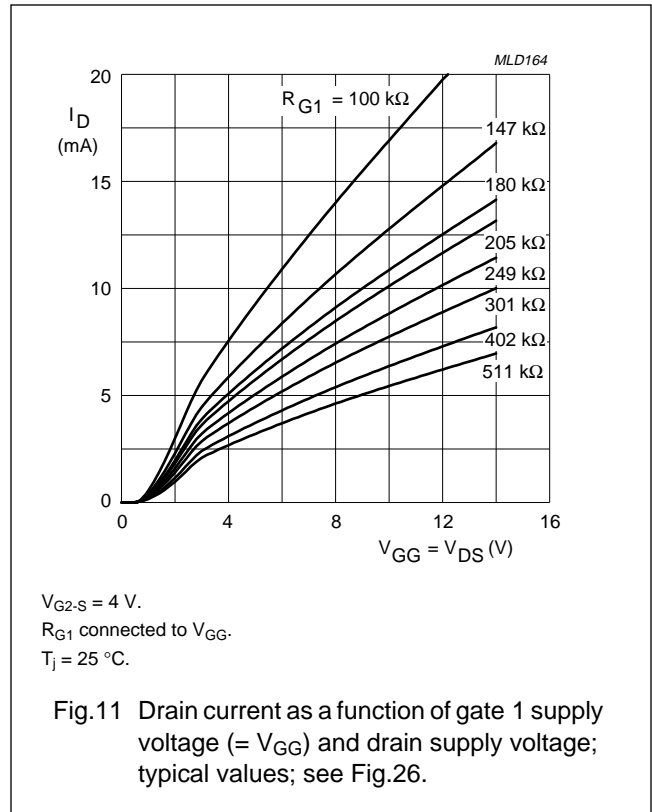
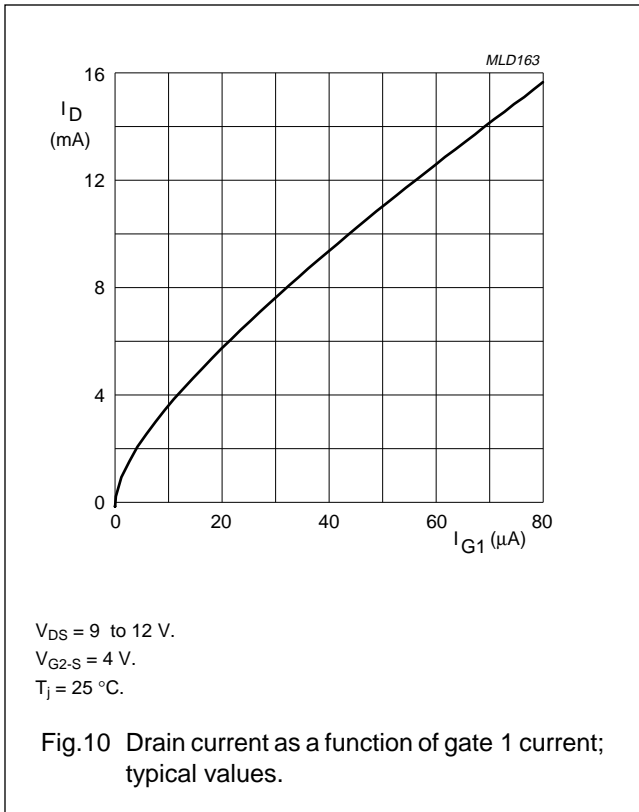
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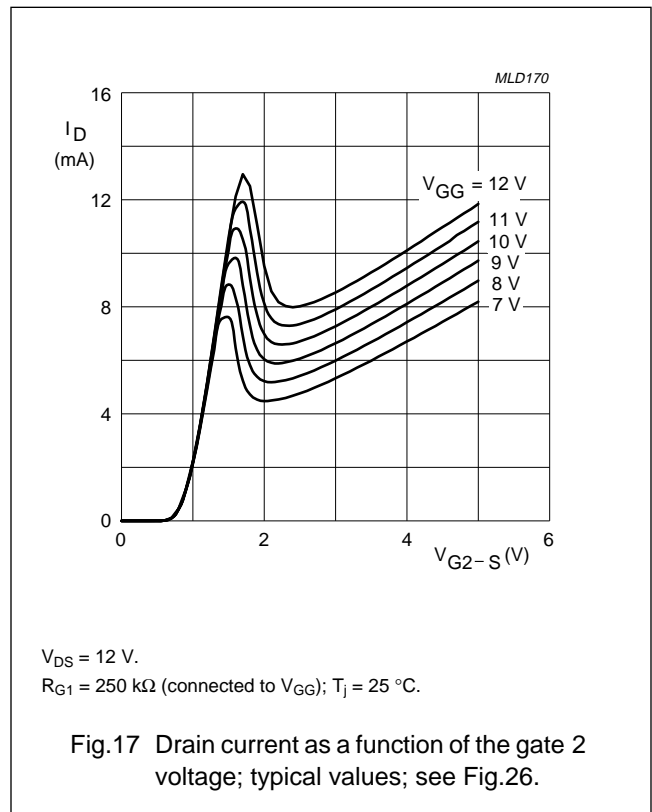
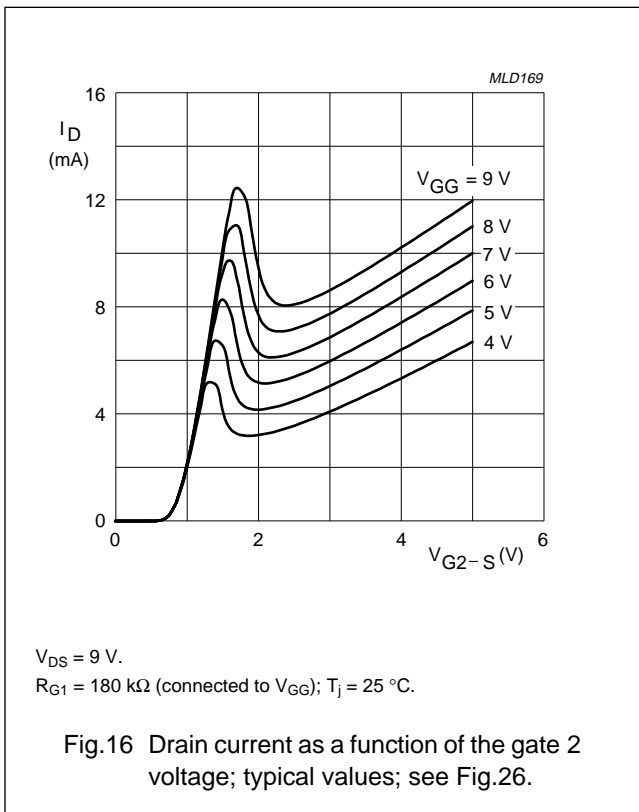
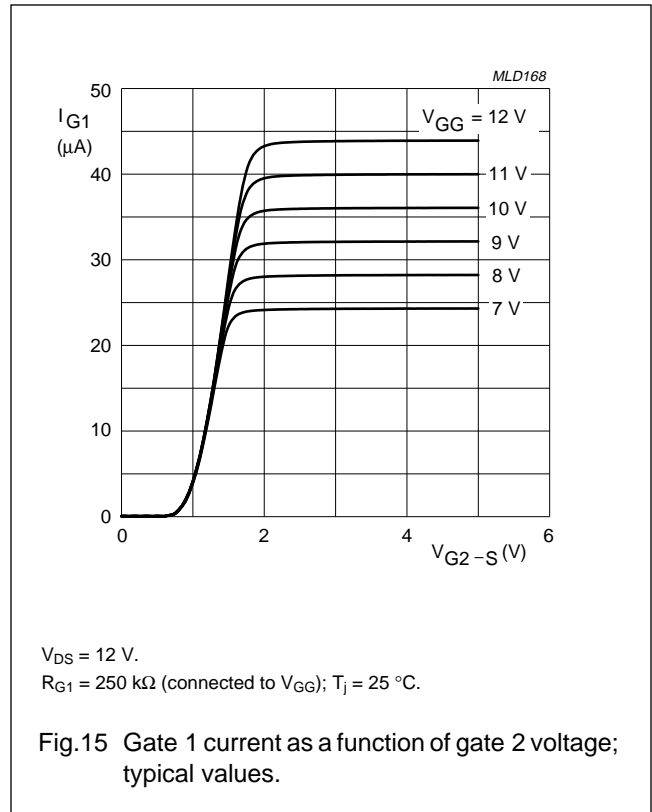
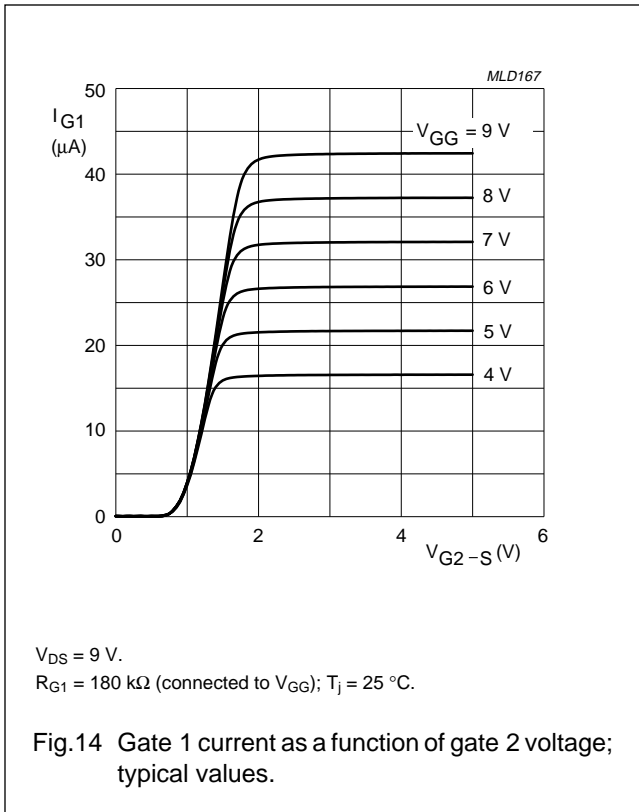
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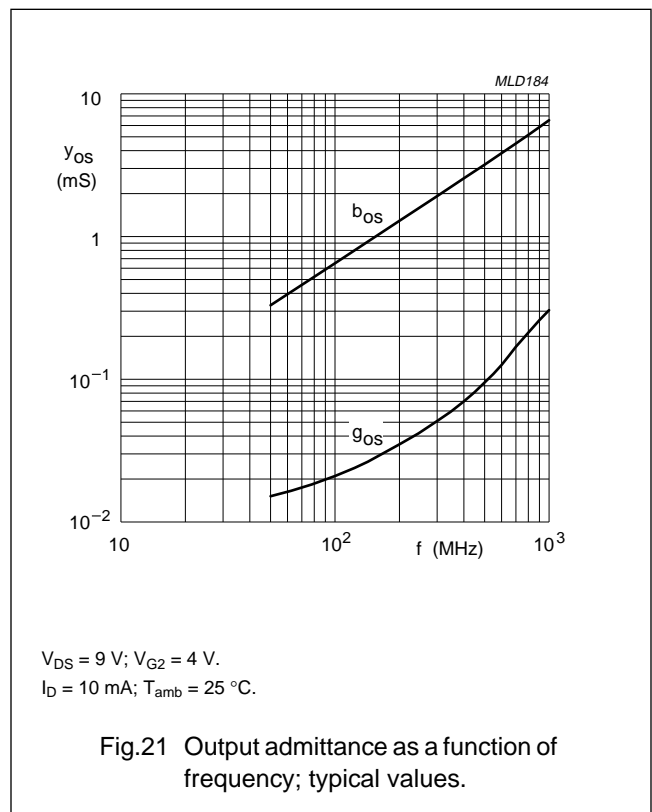
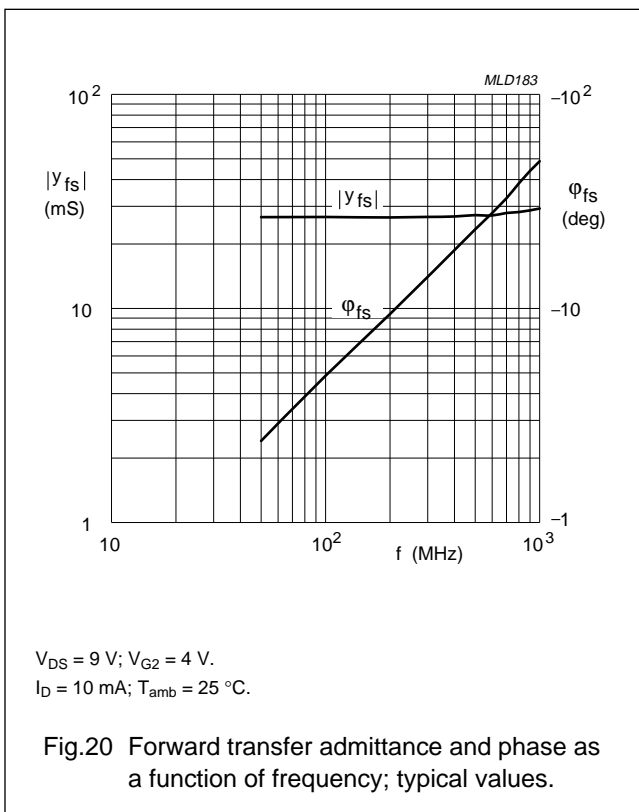
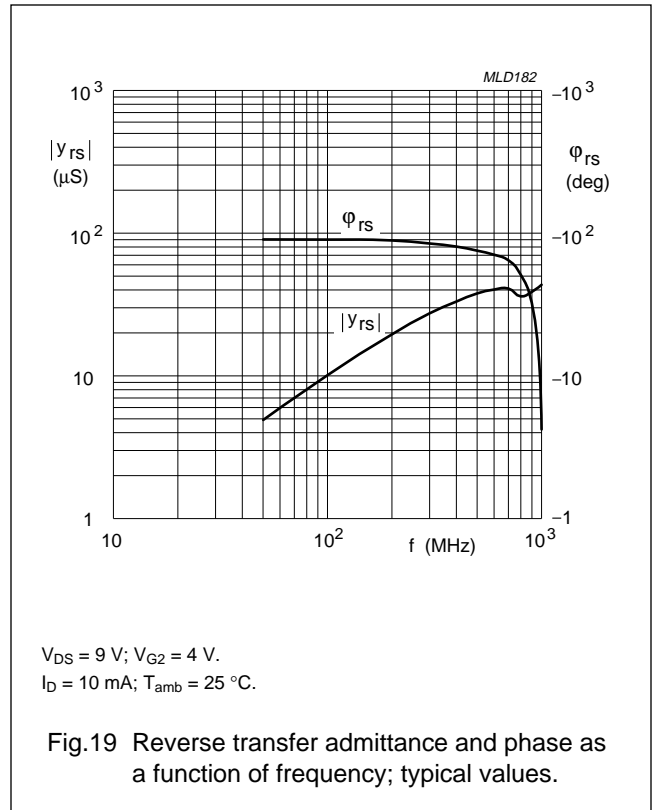
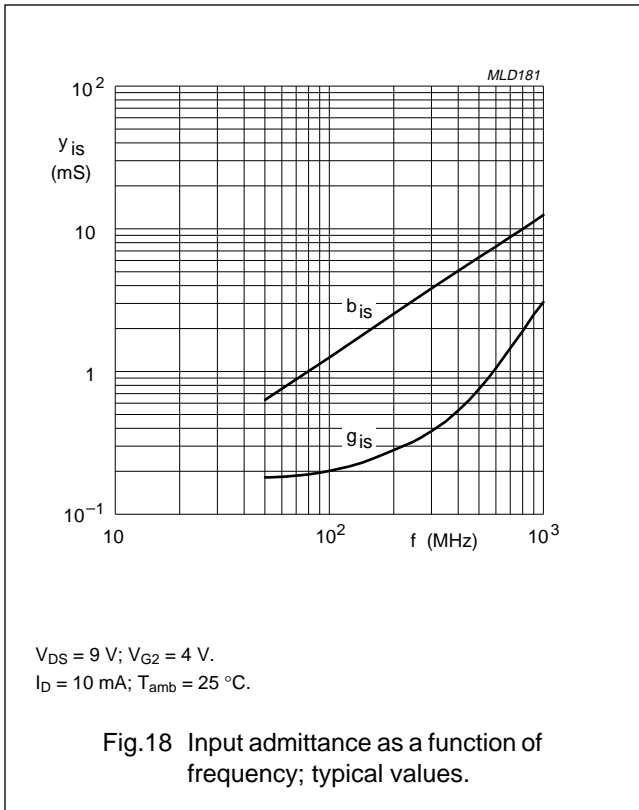
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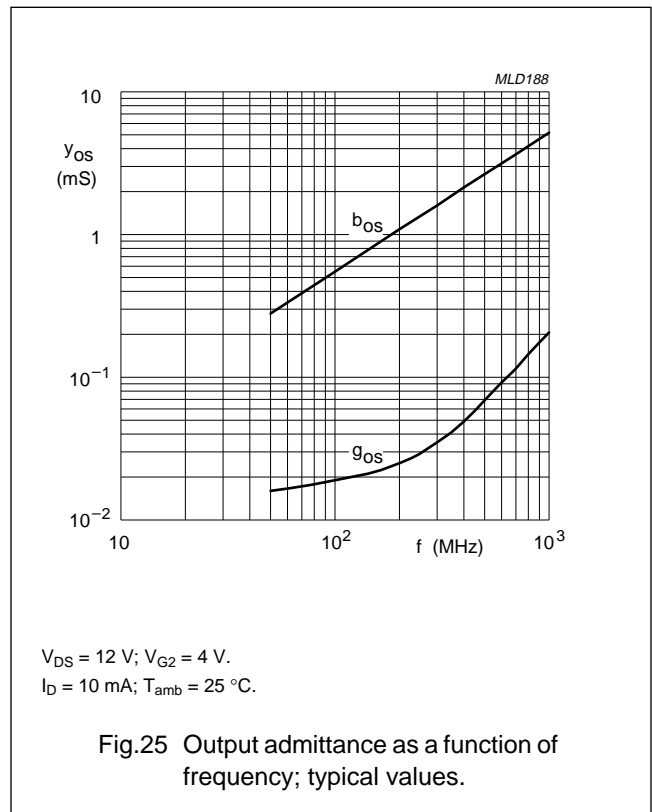
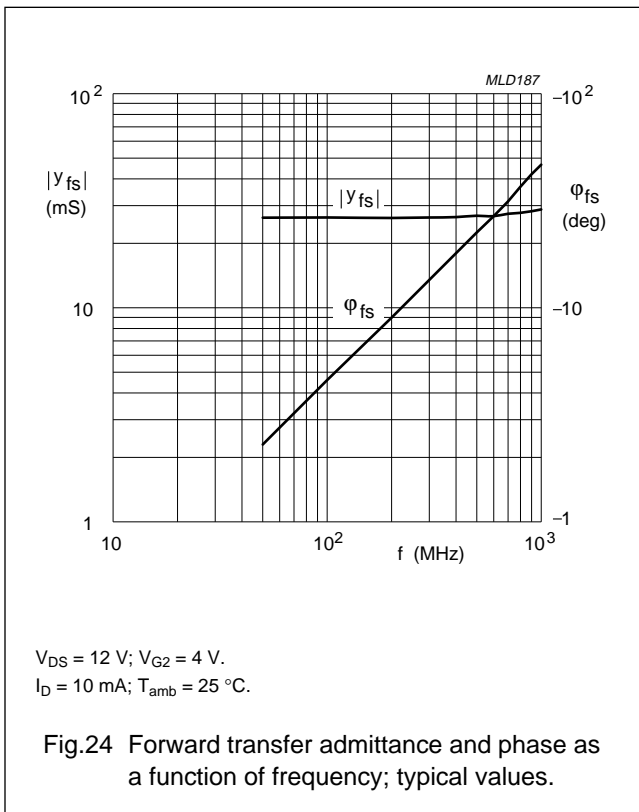
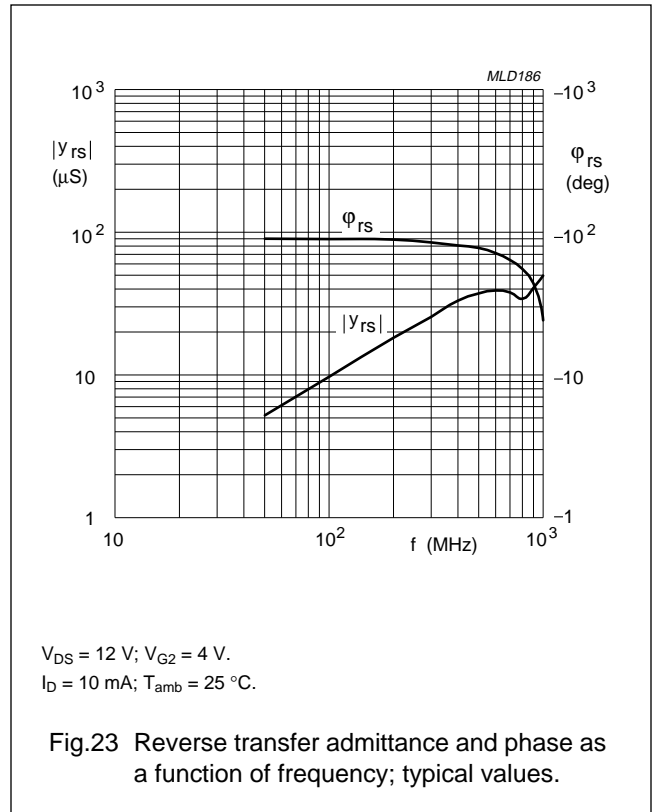
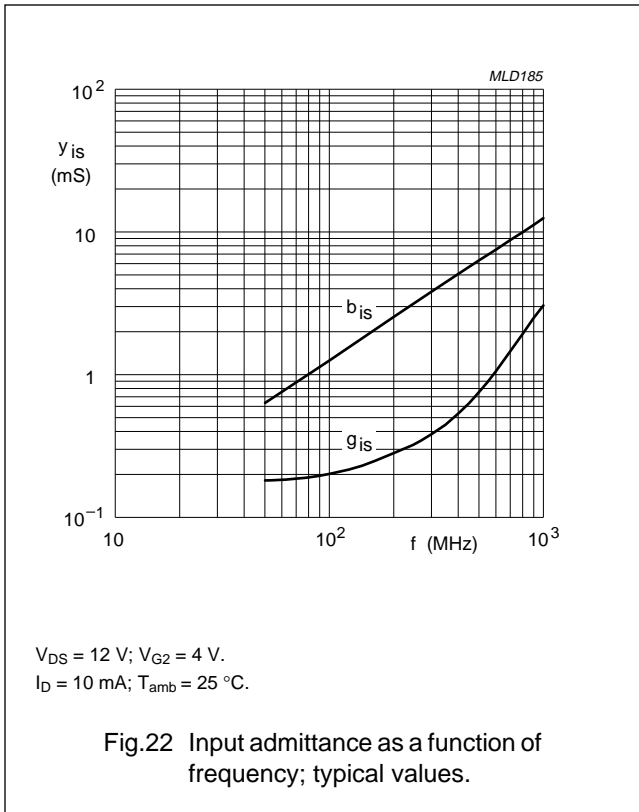
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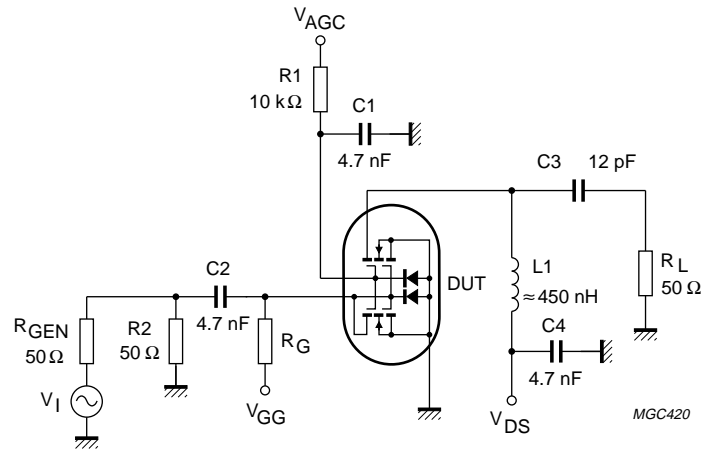
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For $V_{GG} = V_{DS} = 9\text{ V}$, $R_G = 180\text{ k}\Omega$.
 For $V_{GG} = V_{DS} = 12\text{ V}$, $R_G = 250\text{ k}\Omega$.

Fig.26 Cross-modulation test circuit.

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Table 1 Scattering parameters: $V_{DS} = 9\text{ V}$; $V_{G2-S} = 4\text{ V}$; $I_D = 10\text{ mA}$

| f (MHz) | S ₁₁ | | S ₂₁ | | S ₁₂ | | S ₂₂ | |
|------------|----------------------|----------------|----------------------|----------------|----------------------|----------------|----------------------|----------------|
| | MAGNITUDE (ratio) | ANGLE (deg) | MAGNITUDE (ratio) | ANGLE (deg) | MAGNITUDE (ratio) | ANGLE (deg) | MAGNITUDE (ratio) | ANGLE (deg) |
| 50 | 0.985 | -3.9 | 2.618 | 175.1 | 0.001 | 137.9 | 1.000 | -1.9 |
| 100 | 0.981 | -7.3 | 2.602 | 170.5 | 0.001 | 80.4 | 0.999 | -4.0 |
| 200 | 0.975 | -14.4 | 2.577 | 160.7 | 0.002 | 74.0 | 0.995 | -7.6 |
| 300 | 0.965 | -21.6 | 2.555 | 151.6 | 0.002 | 79.3 | 0.994 | -11.3 |
| 400 | 0.947 | -28.3 | 2.513 | 141.8 | 0.003 | 80.5 | 0.992 | -15.0 |
| 500 | 0.927 | -34.9 | 2.449 | 133.4 | 0.003 | 82.8 | 0.988 | -18.5 |
| 600 | 0.913 | -41.7 | 2.339 | 124.6 | 0.003 | 78.9 | 0.984 | -22.0 |
| 700 | 0.890 | -47.9 | 2.361 | 115.4 | 0.003 | 80.6 | 0.982 | -25.3 |
| 800 | 0.869 | -54.0 | 2.302 | 106.4 | 0.003 | 93.9 | 0.979 | -28.8 |
| 900 | 0.845 | -59.7 | 2.228 | 97.6 | 0.003 | 104.8 | 0.976 | -32.1 |
| 1000 | 0.823 | -65.4 | 2.167 | 89.6 | 0.003 | 129.3 | 0.974 | -35.5 |

Table 2 Noise data: $V_{DS} = 9\text{ V}$; $V_{G2-S} = 4\text{ V}$; $I_D = 10\text{ mA}$

| f (MHz) | F _{min} (dB) | Γ _{opt} | | r _n |
|------------|--------------------------|------------------|-------|----------------|
| | | (ratio) | (deg) | |
| 800 | 2.00 | 0.67 | 43.9 | 0.89 |

Table 3 Scattering parameters: $V_{DS} = 12\text{ V}$; $V_{G2-S} = 4\text{ V}$; $I_D = 10\text{ mA}$

| f (MHz) | S ₁₁ | | S ₂₁ | | S ₁₂ | | S ₂₂ | |
|------------|----------------------|----------------|----------------------|----------------|----------------------|----------------|----------------------|----------------|
| | MAGNITUDE (ratio) | ANGLE (deg) | MAGNITUDE (ratio) | ANGLE (deg) | MAGNITUDE (ratio) | ANGLE (deg) | MAGNITUDE (ratio) | ANGLE (deg) |
| 50 | 0.985 | -3.7 | 2.576 | 175.3 | 0.000 | 125.0 | 1.000 | -1.6 |
| 100 | 0.980 | -7.4 | 2.563 | 170.9 | 0.001 | 111.2 | 1.000 | -3.3 |
| 200 | 0.973 | -14.6 | 2.541 | 161.6 | 0.002 | 83.0 | 0.997 | -6.4 |
| 300 | 0.962 | -21.5 | 2.519 | 152.9 | 0.002 | 85.2 | 0.996 | -9.3 |
| 400 | 0.946 | -28.5 | 2.479 | 143.5 | 0.003 | 79.4 | 0.995 | -12.4 |
| 500 | 0.929 | -35.0 | 2.419 | 135.5 | 0.003 | 78.2 | 0.991 | -15.3 |
| 600 | 0.912 | -41.6 | 2.373 | 127.2 | 0.003 | 80.0 | 0.989 | -18.1 |
| 700 | 0.895 | -47.8 | 2.336 | 118.7 | 0.003 | 83.4 | 0.987 | -20.9 |
| 800 | 0.868 | -53.8 | 2.284 | 110.0 | 0.003 | 91.3 | 0.985 | -23.7 |
| 900 | 0.845 | -59.8 | 2.213 | 101.6 | 0.003 | 95.9 | 0.983 | -26.5 |
| 1000 | 0.823 | -65.7 | 2.160 | 94.1 | 0.003 | 112.2 | 0.981 | -29.3 |

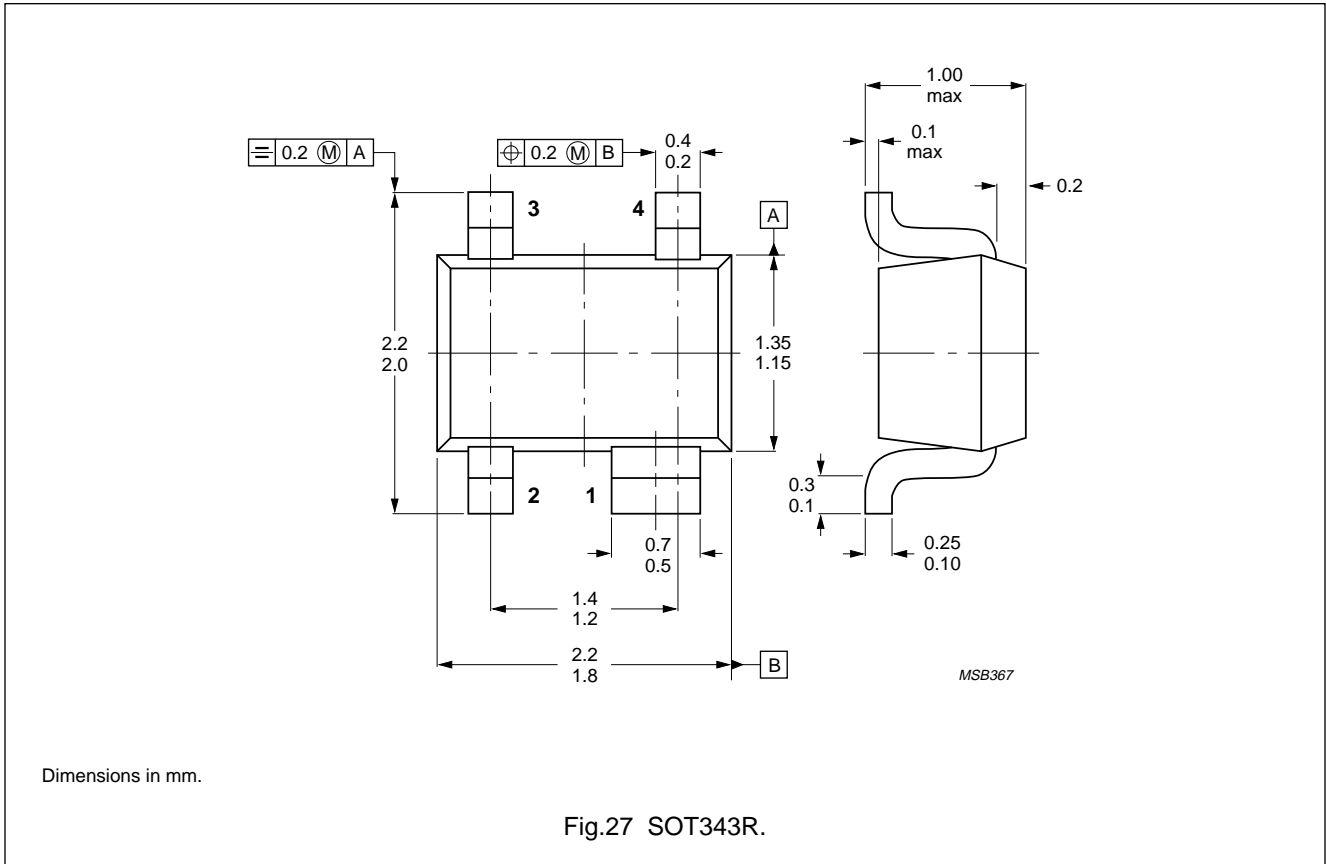
Table 4 Noise data: $V_{DS} = 12\text{ V}$; $V_{G2-S} = 4\text{ V}$; $I_D = 10\text{ mA}$

| f (MHz) | F _{min} (dB) | Γ _{opt} | | r _n |
|------------|--------------------------|------------------|-------|----------------|
| | | (ratio) | (deg) | |
| 800 | 2.00 | 0.66 | 43.3 | 0.97 |

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PACKAGE OUTLINE



Dual-gate MOS-FET

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DEFINITIONS

| Data Sheet Status | |
|---|---|
| Objective specification | This data sheet contains target or goal specifications for product development. |
| Preliminary specification | This data sheet contains preliminary data; supplementary data may be published later. |
| Product specification | This data sheet contains final product specifications. |
| Limiting values | |
| Limiting values given are in accordance with the Absolute Maximum Rating System (IEC 134). Stress above one or more of the limiting values may cause permanent damage to the device. These are stress ratings only and operation of the device at these or at any other conditions above those given in the Characteristics sections of the specification is not implied. Exposure to limiting values for extended periods may affect device reliability. | |
| Application information | |
| Where application information is given, it is advisory and does not form part of the specification. | |

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